## 1 Effect of matching errors on the precision of ratios in integrated circuits.

Let us define the ratio:

$$r = \frac{R_1 + \dots + R_M}{R_{M+1} + \dots + R_{M+N}}$$
(1.1)

where *R* is a quantity (e.g. the resistance) associated to a type of component (e.g. a resistor) and  $R_i$  are the value assumed by *R* on *N*+*M* nominally identical components. Clearly, the nominal value of *r* is M/N.

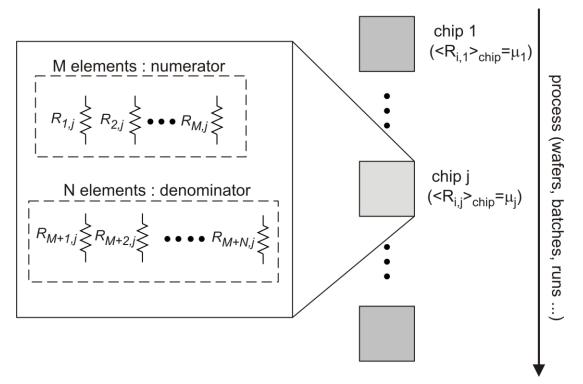


Fig. 1.1. Ratio of *M* over *N* nominally identical resistors.

Let us now consider a series of distinct samples of the same chip, and identify each sample (i.e. each chip) with number *j*. Figure 1.1 illustrate these concepts. With obvious notation, we will indicate the ratio  $r_j$  of chip *j* as:

$$r_{j} = \frac{R_{1,j} + \dots + R_{M,j}}{R_{M+1,j} + \dots + R_{M+N,j}}$$
(1.2)

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The problem here is to determine the standard deviation of ratio r, which expresses the variability of r over a large number of different samples.

For each chip we can consider that the values  $R_{i,j}$  are the result of a stochastic sub-process which is peculiar of that chip. We can define the mean  $\mu_j$  of that sub-process, which can be regarded as the average of an infinite number of nominally identical components  $R_{i,j}$ , all produced in the same chip *j*. This is clearly an ideal operation, since the number of component that can be included into the same single chip is finite and generally small. We also observe that  $\mu_j$  varies widely from one chip to another owing to process variations (global variations or <u>global errors</u>). These variations are clearly larger if we consider chips that comes from different runs, but this point is not essential here. We can write the  $R_{i,j}$ values as:

$$R_{i,j} = \mu_j + \delta R_{i,j} \tag{1.3}$$

It can be easily demonstrated that, if the mean  $\mu_j$  is really the limit of the average calculated on an ideally infinite number of <u>components</u>, the deviations  $\delta R_{i,j}$  (local variations or <u>local errors</u>) of two distinct components are independent of each other, that is:

$$<\delta R_{k,j}\delta R_{h,j}>_{proc}=0$$
 for  $h \neq k$  (1.4)

where operator  $\langle \rangle_{proc}$  indicates the average performed over the whole process, i.e. when j varies from 1 to  $\infty$ .

Using (1.3) we can write the ratio (1.2) as:

$$r_{j} = \frac{\left(\mu_{j} + \delta R_{1,j}\right) + \dots + \left(\mu_{j} + \delta R_{M,j}\right)}{\left(\mu_{j} + \delta R_{M+1,j}\right) + \dots + \left(\mu_{j} + \delta R_{M+N,j}\right)} = \frac{M\mu_{j} + \sum_{i=1}^{M} \delta R_{i,j}}{N\mu_{j} + \sum_{i=M+1}^{M+N} \delta R_{i,j}}$$
(1.5)

which can be rewritten as:

$$r_{j} = \frac{M}{N} \frac{1 + \frac{1}{M} \sum_{i=1}^{M} \frac{\delta R_{i,j}}{\mu_{j}}}{1 + \frac{1}{N} \sum_{i=M+1}^{M+N} \frac{\delta R_{i,j}}{\mu_{j}}}$$
(1.6)

If 
$$\frac{1}{M} \left| \sum_{i=1}^{M} \frac{\delta R_{i,j}}{\mu_j} \right| \ll 1 \quad \text{and} \quad \frac{1}{N} \left| \sum_{i=M+1}^{M+N} \frac{\delta R_{i,j}}{\mu_j} \right| \ll 1$$
(1.7)

Paolo Bruschi – Effect of matching errors on the precision of ratios in integrated circuits – PSM 2019 we can apply first order Taylor approximation and easily find that:

$$r_{j} \cong \frac{M}{N} \left( 1 + \sum_{i=1}^{M} \frac{\delta R_{i,j}}{M \mu_{j}} - \sum_{i=M+1}^{M+N} \frac{\delta R_{i,j}}{N \mu_{j}} \right)$$
(1.8)

$$\frac{\left(r_{j}-\frac{M}{N}\right)}{\frac{M}{N}} = \frac{\Delta r_{j}}{r_{nom}} \cong \left(\sum_{i=1}^{M} \frac{\delta R_{i,j}}{M \mu_{j}} - \sum_{i=M+1}^{M+N} \frac{\delta R_{i,j}}{N \mu_{j}}\right)$$
(1.9)

where  $r_{nom}$  is the nominal value of ratio r, i.e. M/N. Now, considering Eq. (1.4), stating that all  $\delta R_{i,j}$  are uncorrelated, we find:

$$\frac{\sigma_{\Delta r}^2}{r_{nom}^2} \cong \frac{1}{M^2} \sum_{i=1}^M \sigma_{\frac{\delta R_i}{\mu_j}}^2 + \frac{1}{N^2} \sum_{i=M+1}^{M+N} \sigma_{\frac{\delta R_i}{\mu_j}}^2$$
(1.10)

Note that averages  $\mu_j$  is the average of the quantity R of elements in chip j, thus the ratios  $\delta R_{i,j}/\mu_j$  are the relative ( $\delta R/R$ ) local errors. Considering that no systematic error is present, the standard deviations of  $\delta R_{i,j}/\mu_j$  of all components on the chip ( $R_1 \dots R_{N+M}$ ) are equal, so that, by simple passages, we get:

$$\frac{\sigma_{\Delta r}}{r_{nom}} \cong \sigma_{\frac{\delta R}{R}} \sqrt{\frac{1}{N} + \frac{1}{M}}$$
(1.11)

Eq. (1.11) relates the standard deviation of the relative error on the ratio *r* to the standard deviation of the relative mismatch error of the quantity *R* with respect of the average over a single chip,  $\mu_j$ . Since the data that is generally reported is the standard deviation of the relative *matching error* between two elements,  $\Delta R$ , than we have to find a relationship between  $\sigma_{\delta R}$  and  $\sigma_{\Delta R}$ .

Considering for simplicity two elements  $R_1$  and  $R_2$ , we can write:

$$\Delta R = R_{1,j} - R_{2,j} = \delta R_{1,j} - \delta R_{2,j}$$
(1.12)

Using again the statistical independence of the terms  $\delta R_{i,j}$ , we get:

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$$\sigma_{\Delta R}^{2} = \sigma_{\delta R_{1}}^{2} + \sigma_{\delta R_{2}}^{2} = 2\sigma_{\delta R}^{2} \implies \sigma_{\delta R} = \frac{1}{\sqrt{2}}\sigma_{\Delta R}$$
(1.13)

With simple substitutions, we can rewrite (1.11) as:

$$\frac{\sigma_r}{r_{nom}} \cong \sigma_{\frac{\Delta R}{R}} \left[ \frac{1}{\sqrt{2}} \sqrt{\frac{1}{N} + \frac{1}{M}} \right]$$
(1.14)